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PATENT APPLICATION
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TECHNOLOGY CENTER 2800

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Akira SHIMOKOHBE et al.

Group Art Unit: 2813

Application No.: 09/556,795

Examiner: Asok K. Sarkar

Filed: April 25, 2000

Docket No.: 106096

For: A THIN FILM-STRUCTURE AND A METHOD FOR PRODUCING THE SAME

AMENDMENT

Director of the U.S. Patent and Trademark Office
Washington, D.C. 20231

Sir:

In reply to the Office Action mailed July 10, 2001, please amend the above-identified application as follows:

IN THE CLAIMS:

Please replace claim 3 as follows:

3. (Twice Amended) A method for producing a thin film-structure comprising the steps of:

forming on a substrate a thin film made of an amorphous material having a supercooled liquid phase region,

heating the thin film to a temperature within the supercooled liquid phase region and thereby deforming the thin film to a given shape without the use of an external force, and

cooling the thin film to room temperature from the temperature within the supercooled liquid phase region to stop deforming the thin film and thereby forming the thin film-structure.